# IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: Mamoru NAKASUJI et al.

Serial Number: 09/891,611

Group Art Unit:

Filed: June 27, 2001

Examiner: Unassigned

NSPECTION SYSTEM BY CHARGED PARTICLE BEAM AND METHOD OF MANUFACTURING DEVICES USING THE SYSTEM

<u>INFORMATION DISCLOSURE STATEMENT</u> <u>PURSUANT TO 37 CFR 1.97(b)</u>

Commissioner for Patents Washington, D.C. 20231

January 18, 2002

Sir:

The attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached Form PTO-1449. One copy of each of these documents is attached.

No fee or certification is required in connection with this Information Disclosure Statement, since it is being submitted prior to the issuance of a first official action on the merits or expiration of the three month period following the filing date or the entry of the national stage of the above-captioned application.

The above information is presented so that the Patent and Trademark Office can, in the first instance, determine any materiality thereof to the claimed invention. See 37 CFR 1.104(a) concerning the PTO duty to consider and use any such information. It is respectfully requested that the information be expressly considered during the prosecution of this application, and that the documents cited in the attached Form PTO-1449 be made of record therein and appear on the first page of any patent to issue therefrom.

Serial No.:

09/891,611

Applicant:

Mamoru NAKASUJI et al.

Attorney Docket No. 010817

Page 2

The Commissioner is authorized to charge our Deposit Account No. 01-2340 for any fee which is deemed by the Patent and Trademark Office to be required to effect consideration of this statement.

Respectfully submitted,

ARMSTRONG, WESTERMAN & HATTORI, LLP

William G. Kratz, Jr. Attorney for Applicant Reg. No. 22,631

Attorney Docket No. **010817** 1725 K Street, N.W., Suite 1000 Washington, D.C. 20006

Tel: (202) 659-2930 Fax: (202) 887-0357

WGK/rlb

Enclosures:

European Search Report

PTO-1449 w/ 40 References

**INFORMATION DISCLOSURE CITATION** PTO-1449

Atty. Docket No. 010817

Serial No. 09/891,611

Applicant: Mamoru NAKASUJI et al.

Filing Date: June 27, 2001

Group Art Unit:

# FOREIGN PATENT DOCUMENTS

			AGN TATENT I	DOCUMENTS.	
OIPE	1095	Document No.	Date	Country	Translation (Yes or No)
JAN 1 8 20		52-115161 -	09/27/77	JAPAN	ABSTRACT
JAN 1 8 ZU	<b>₩X</b> B	52-117567	10/03/77	JAPAN	ABSTRACT
RADEN	AC	57-072326 -	05/06/82	JAPAN	ABSTRACT
	AD	57-125871_√	08/05/82	JAPAN	ABSTRACT
	AE	60-000741	01/05/85	JAPAN	ABSTRACT
	AF	62-195838 🕏	08/28/87	JAPAN	ABSTRACT
	AG	03-022339 🖈	01/30/91	JAPAN	ABSTRACT
<u> </u>	AH	03-053439 √	03/07/91	JAPAN	ABSTRACT
	AI	03-102814 🗸	04/30/91	JAPAN	ABSTRACT
	AJ	03-266350 🎸	11/27/91	JAPAN	ABSTRACT
	AK	03-276548	12/06/91	JAPAN	ABSTRACT
	AL	04-266350	09/22/92	JAPAN	ABSTRACT
	AM	05-063261 🗸	03/12/93	JAPAN	ABSTRACT
	AN	05-251316 ·J	09/28/93	JAPAN	ABSTRACT
	AO	07-065766 ⋨	03/10/95	JAPAN	ABSTRACT
	AP	08-138611 🔞	05/31/96	JAPAN	ABSTRACT
	AQ	09-311112 -	12/02/97	JAPAN	ABSTRACT
	AR	كر 10-062503	03/06/98	JAPAN	ABSTRACT
	AS	10-177952 🎸	06/30/98	JAPAN	ABSTRACT
	AT	11-132975 √	05/21/99	JAPAN	ABSTRACT
	AU	2000-090868	03/31/00	<b>JAPAN</b>	ABSTRACT

Examiner

Date Considered

**INFORMATION DISCLOSURE CITATION** PTO-1449

Atty. Docket No. 010817

Serial No. 09/891,611

Applicant: Mamoru NAKASUJI et al.

Filing Date: June 27, 2001

Group Art Unit:

## **U.S. PATENT DOCUMENTS**

Examiner Initial		Document No.	Name	Date	Class	Subclass	Filing Date (If appropriate)
<u> </u>	<b>%</b> V	6,125,522	Nakasuji	10/03/00			11/12/96
3002 8 1 MAL	W XX	6,087,667	Nakasuji et al.	07/11/00			09/30/97
MADEMA	XX	5,994,704	Nakasuji	11/30/99			10/03/97
PADEME	AY	5,981,947	Nakasuji etal.	11/09/99			02/03/98
	AZ	5,892,224	Nakasuji	04/06/99			05/09/97
	BA	5,770,863	Nakasuji	06/23/98			10/24/96
<del></del>	BB	5,763,893	Nakasuji	06/09/98			12/16/96
	BC	5,751,538	Nakasuji	05/12/98			09/26/96
	BD	5,747,819	Nakasuji et al.	05/05/98			10/30/96
<del></del>	BE	5,362,968	Miyoshi et al.	11/08/94			09/27/93
	BF	5,359,197	Komatsu et al.	10/25/94	÷		07/16/93
	BG	4,912,052	Miyoshi et al.	03/27/90			09/23/88

### **OTHER DOCUMENTS**

	BH /	Low Voltage and high speed operating electrostatic wafer chuck using sputtered tantalum oxide membrane, Mamoru Nakasuji et al., J. Vac. Sci. Technol. A 12(5), Sep/Oct 1994, American Vacuum Society pp. 2834-2839.
	BI ,	High -Emittance and Low-Brightness Electron Gun for Reducing-Image Projection System: Computer Simulation, Mamoru Nakasuji et al., Jpn. J. Appl. Phys. Vol. 36 (1997) pp.2404-2408.
	BJ √	H. Hayashi, et al., LSI Testing Symposium 1998, Minutes of the meeting, P160 (1998) (partial translation)
Examiner		Date Considered

## OTHER DOCUMENTS

	STABLE DOCUMENTS					
	INFORMATION DISCLOSURE CITATION PTO-1449			Atty. Docket No. 010817	Serial No. 09/891,611	
				Applicant: Mamoru NAKASUJI et :	al.	
ļ				Filing Date: June 27, 2001	Group Art Unit:	
BK v Multi-Beam Concepts for Nanometer Devices, B. Lischke et al., Japanese Journal of Applied Physics, Vol. 28, No.10, October 1989, pp. 2058-2064.  An electron-beam inspecting system for x-ray mask production, P. Sandland et al., Vac. Sci. Technol. B9 (6), Nov/Dec. 1991, American Vacuum Society, pp.3005-3009.  Requirements and performance of an electron-beam column designed for x-ray mask production, W.D. Meisburger et al., J. Vac. Sci. Technol. B9 (6), Nov/Dec 1991, American Vacuum Society, pp.3010-3014.  BN Table 5-1 Work Function in Metals page 116.			9, pp. 2058-2064.  mask production, P. Sandland et al., J  merican Vacuum Society, pp.3005-  beam column designed for x-ray mask			
	Examiner	caminer Date Considered				